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6, 5295Voltage-controlled rotation of magnetic
anisotropy in the Ni₉₀Fe₁₀/BaTiO₃(001)
heterostructureA. Begué,^{ab} M. W. Khaliq,^c N. Cotón,^{ab} I. Lorenzo-Feijoo,^a M. A. Niño,^c
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In this work, we demonstrate the voltage control of magnetic anisotropy in a strain-mediated Ni₉₀Fe₁₀/BaTiO₃(001) heterostructure. In the pristine state of the heterostructure, the magneto-optical Kerr effect measurements show a transcritical hysteresis loop for the Ni₉₀Fe₁₀ film, indicating a weak perpendicular anisotropy. This was further confirmed by X-ray magnetic circular dichroism – photo-emission electron microscopy, revealing stripe domains in this film. X-ray diffraction analysis of the BaTiO₃ substrate under varying electric fields was used to analyze the orientation of ferroelectric domains. These results indicated that BaTiO₃ exhibits two distinct states depending on the applied electric field: one with domains aligned with the electric field and another with random domain orientation when the field is removed. After substrate poling, the Ni₉₀Fe₁₀ layer switches from weak perpendicular anisotropy to an in-plane uniaxial magnetic anisotropy, with the in-plane direction of anisotropy being controllable by 90° through an electric field. This effect is due to an efficient strain transfer from BaTiO₃ to the Ni₉₀Fe₁₀ lattice, induced by ferroelectric polarization, as shown by XRD. Remarkably, this rotation of the magnetic anisotropy leads to an enhanced converse magnetoelectric coupling value of 1.43 μs m⁻¹, surpassing previously reported values for other BaTiO₃-based heterostructures by an order of magnitude. These results emphasize the potential of Ni₉₀Fe₁₀ alloys for next-generation magnetoelectric devices.

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Introduction

The search for increased efficiency in technological processes has driven research into innovative methods for material manipulation, particularly in the area of magnetization control.^{1–4} One promising approach is the field of voltage control of magnetic anisotropy (VCMA), which has garnered attention for its capability to control the magnetization of magnetic materials using voltage. VCMA systems offer efficient control of magnetization with low power consumption at room temperature and are expected to play a key role in the next generation of spintronic applications.^{5,6} This low-power operation is particularly relevant for devices that can be used to control skyrmions,^{7,8} manipulate domain walls,^{9,10} or perform

weighted summations in neuromorphic computing architectures.^{11–13} The converse magnetoelectric coupling, $\alpha_E = \mu_0 \frac{\Delta M}{\Delta E}$, quantifies the relationship between the applied electric field, ΔE , and the resulting changes in magnetization, ΔM .^{14–16} This parameter is a key indicator of how strongly the electric field and magnetization are coupled.

Several strategies have been explored to achieve VCMA, one of which involves single-phase multiferroics. These materials exhibit several ferroic phases, *i.e.* combining ferroelectricity and ferromagnetism. Notable examples include TbMnO₃, with $\alpha_E = 10^{-5} \mu\text{s m}^{-1}$,¹⁷ Ni₃B₇O₁₃I with $10^{-3} \mu\text{s m}^{-1}$,¹⁸ and Cr₂O₃ at $4.1 \times 10^{-6} \mu\text{s m}^{-1}$.¹⁹ However, these values are relatively low compared to those reported for hybrid multiferroics, which integrate two distinct materials with different ferroic phases. Examples such as BiFeO₃/BaTiO₃ with $\alpha_E = 0.2 \mu\text{s m}^{-1}$,²⁰ NFO/PZT with $0.8 \mu\text{s m}^{-1}$,²¹ and FeRh/BaTiO₃ with $16 \mu\text{s m}^{-1}$ (ref. 22) demonstrate significantly higher coupling constants than those found in single-phase multiferroics. These values make hybrid multiferroics more suitable for practical applications, providing greater opportunities for their use in VCMA applications.^{23,24}

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Among the different hybrid multiferroics suitable for VCMA systems, our focus will be on strain-coupled systems. These systems present strong converse magnetoelectric coupling and exhibit low heat dissipation losses.^{25,26} They consist of a magnetostrictive layer coupled to a ferroelectric substrate. When voltage is applied to the substrate, it undergoes deformation, which is transmitted to the magnetostrictive layer. This deformation, due to the Villari effect, affects the magnetic anisotropy of the magnetostrictive layer. To achieve high coupling, it is desirable to use substrates with high piezoelectric values and magnetostrictive layers with high magnetostriction and weak magnetic anisotropy, facilitating control from the strain of the substrate.^{23,24}

Ferroelectric substrates with high piezoelectric constants are commonly made from Pb-based materials, such as $\text{Pb}[\text{Zr}_x\text{Ti}_{1-x}]\text{O}_3$ (PZT)^{27,28} and $\text{Pb}(\text{Mg}_{1/3}\text{Nb}_{2/3})\text{O}_3$ – PbTiO_3 (PMN–PT).^{29–33} However, there is growing concern about the use of Pb in materials, leading to a search for alternatives. Among these alternatives, BaTiO_3 (BTO), a well-known ferroelectric material with a perovskite-like structure, has emerged as a promising candidate, particularly for VCMA systems operating at room temperature. BTO generates strain through three distinct mechanisms: photostriction, phase change, and voltage induction. Photostriction, where the material changes dimensions upon exposure to light, holds promise for applications in light-driven actuators and sensors.^{34–36} Phase change deformation is based on the lattice distortion that occurs during phase transitions, such as from tetragonal to cubic, driven by temperature changes.^{37–39} Voltage induction, on the other hand, relies on the piezoelectric properties of BTO and is particularly relevant for VCMA heterostructures.^{40–42} For example, Fe/BTO ,⁴⁰ FeGa/BTO ,^{42,43} and FeRh/BTO ^{22,41} have demonstrated the potential of BTO for VCMA applications.

For the magnetostrictive layer, we explore alternatives to rare-earth materials like terfenol-D, despite its magnetostrictive properties, due to its environmental impact.⁴⁴ Instead, we focus on Ni–Fe alloys, which are commonly found in the literature and are environmentally friendly. This study focuses on the $\text{Ni}_{90}\text{Fe}_{10}$ composition rather than pure Ni, Fe, or other alloys to balance magnetostriction and minimize out-of-plane (OOP) magnetic anisotropy for in-plane (IP) magnetization control. The magnetostriction of the alloy is $\lambda_{\text{Ni}_{90}\text{Fe}_{10}} = -22$ ppm,⁴⁵ compared to $\lambda_{\text{Ni}} = -33$ ppm and $\lambda_{\text{Fe}} = -9.3$ ppm.⁴⁶ Although Ni exhibits higher magnetostriction, electrodeposited thick films present OOP anisotropy,⁴⁷ that makes it unsuitable for IP rotation, as it requires excessive strain. Our previous studies indicate that at ~ 11 at% Fe content, the anisotropy transitions from OOP to IP.⁴⁷ Beyond this point, increasing Fe content weakens magnetostriction, making $\text{Ni}_{90}\text{Fe}_{10}$ the optimal composition for maximizing magnetostriction while maintaining favorable anisotropy. Additionally, we have demonstrated the effectiveness of electrodeposited $\text{Ni}_{90}\text{Fe}_{10}$ in VCMA systems, reporting a converse magnetoelectric coupling of $0.205 \mu\text{s m}^{-1}$ on $\text{BTO}(011)$ under the piezoelectric regime.⁴⁸ Here, we investigate magnetic anisotropy control on the $\text{BTO}(001)$ surface, focusing on its ferroelectric behavior, which involves the

switching of ferroelectric domains. This process can induce greater strain compared to $\text{BTO}(011)$, where the material remains in the piezoelectric regime and the polarization changes occur without ferroelectric domain switching. Moreover, the use of electrodeposition offers a cost-effective and scalable alternative to sputtering or evaporation, enabling the fabrication of thicker films with ease. While these methods have previously shown good results for depositing magnetostrictive materials on BTO substrates, our work demonstrates that electrodeposited films can achieve even better performance for strain-coupled systems, enabling efficient VCMA and making them suitable for transfer to industrial applications.

In this work, we first examined the response of the BTO substrate using X-ray diffraction (XRD) to analyze the ferroelectric domain configuration during active poling and at electrical remanence. Subsequently, we investigated the magnetic anisotropy of the NiFe layer in response to changes in the BTO substrate caused by poling, using magneto-optical Kerr effect (MOKE) measurements and photo emission electron microscopy with X-ray magnetic circular dichroism (XMCD–PEEM) contrast. A value of $\alpha_E = 1.43 \mu\text{s m}^{-1}$ for the heterostructure was achieved through the application of 0.4 MV m^{-1} , which revealed a high coupling between the layer and the substrate, enabling the manipulation of the IP uniaxial anisotropy of the NiFe layer.

Experimental section

The $\text{Ni}_{90}\text{Fe}_{10}$ layer was electrodeposited onto a BTO substrate (MSE supplies) with a thickness of $0.5 \text{ mm} \pm 0.015 \text{ mm}$. The substrate had been prepared with a metallic bilayer of Ti (15 nm)/Au (50 nm) evaporated on both sides to make both surfaces of the BTO conductive. These bilayers are essential for the electrodeposition of the NiFe layer and also for the application of a perpendicular electric field to the heterostructure (as depicted in Fig. 1a). The $\text{Ni}_{90}\text{Fe}_{10}$ layer, with a thickness of $1.5 \mu\text{m}$, was deposited under controlled conditions using a PalmSens EmStat3 system in a three-electrode cell configuration at room temperature. In this setup, the top Au surface of the BTO substrate served as the working electrode, a platinum mesh was used as the counter electrode, and an Ag/AgCl (3 M NaCl) electrode acted as the reference. The electrolyte solution, water-based with a pH of 2.4, consisted of 0.4 M H_3BO_3 , 0.017 M saccharine, 0.7 M NiSO_4 , and 0.02 M FeSO_4 . A constant deposition voltage of -1.20 V was applied without stirring, specifically chosen to promote the formation of magnetic stripe domains in the NiFe.^{45,47,49} The film thickness was controlled by monitoring the charge at the working electrode throughout the process. Following deposition, the composition of the NiFe layer was characterized using energy dispersive X-ray spectroscopy, performed with a JEOL JSM 6400 instrument operating at an acceleration voltage of 15 kV.

XRD in reciprocal space configuration was employed to investigate the structural properties of BTO under various applied electric fields. The measurements were conducted



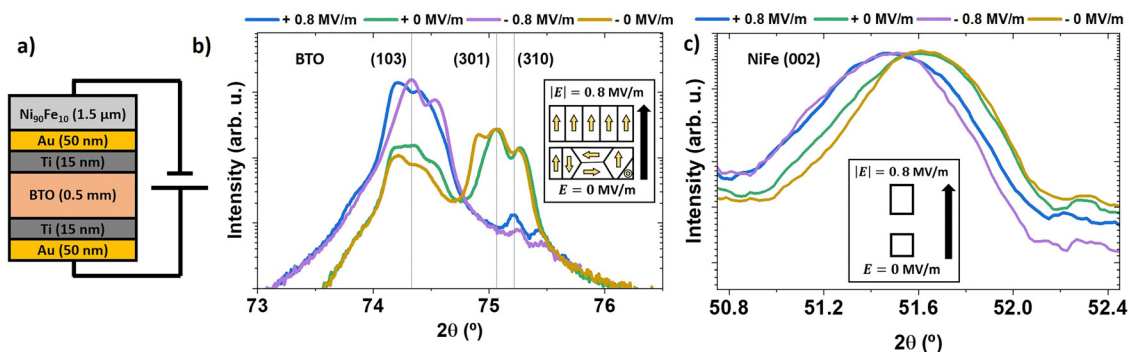


Fig. 1 (a) Schematic drawing of the studied $\text{Ni}_{90}\text{Fe}_{10}/\text{BaTiO}_3(001)$ heterostructure, illustrating how the electric field is applied in the OOP direction. (b) Reciprocal space XRD for BTO at several applied electric fields. Theoretical reflections {103} are shown to identify the peaks. Inset: Schematic cross-section of BTO lattice with poling (top) and without poling (bottom). Yellow arrows indicate the direction of the c -axis (polarization), and the black arrow indicates the direction of the applied electric field. (c) XRD $\theta-2\theta$ measurement of NiFe(002) reflection at several applied electric fields. Inset: Schematic cross-section of NiFe lattice with poling (top) and without poling (bottom). Black arrow indicates the direction of the applied electric field.

using a D8 Bruker diffractometer, utilizing $\text{Cu K}\alpha_1$ ($\lambda = 1.54056 \text{ \AA}$) and $\text{Cu K}\alpha_2$ ($\lambda = 1.54439 \text{ \AA}$) wavelengths. The lattice parameters used to calculate the expected position of diffraction spots in reciprocal space are $a = b = 3.994 \text{ \AA}$ and $c = 4.038 \text{ \AA}$.⁵⁰ The {103} reflection was selected for its simplicity in interpretation compared to other reflections, *i.e.* {002}. This reflection offers a single peak in ω , allowing precise intensity centering and simultaneous observation of the multiferroic domain configuration.

We conducted MOKE measurements at room temperature using the longitudinal configuration with p-polarized light. The experimental setup, which was custom-built, includes a 650 nm wavelength laser with a power output of 5 mW operating at 10 kHz, two polarizers, a photodetector, and an electromagnet capable of generating a magnetic field of up to 200 mT. The signal from the photodetector is processed by a Stanford research SR830 lock-in amplifier to isolate the Kerr effect signal. The applied magnetic field strength is monitored using an FH-55 magnetometer, and the voltage is supplied through a voltage source to a custom sample holder.

Magnetic imaging was carried out using XMCD-PEEM at the CIRCE beamline of the ALBA Synchrotron.⁵¹ The imaging was performed using low-energy secondary electrons (with kinetic energies around 1–2 V) at the Fe L_3 absorption edge, approximately 707 eV photon energy. Magnetic contrast was achieved by subtracting pixel-wise images taken with circularly polarized X-rays of opposite helicities (left and right handed circular polarization).

Results and discussion

First of all, the behavior of the BTO substrate under several poling fields was examined using XRD to investigate how ferroelectric domains align in response to the applied electric field. The electric field was cycled through $+0.8 \text{ MV m}^{-1}$, $+0 \text{ MV m}^{-1}$, -0.8 MV m^{-1} , and back to -0 MV m^{-1} . Fig. 1b presents the reflections obtained from reciprocal space

measurements. The expected reflection positions (guidelines) for the tetragonal structure of BTO are based on lattice parameters $a = b = 3.994 \text{ \AA}$ and $c = 4.038 \text{ \AA}$.⁵⁰ Under both polarities, $\pm 0.8 \text{ MV m}^{-1}$ bias, only the (103) reflection exhibits intensity. In contrast, at $E = 0 \text{ MV m}^{-1}$, multiple reflections, including (103), (301), and (310), are observed. The (103) reflection is related to the c -axis of BTO pointing OOP, while the (301) and (310) reflections are associated with the c -axis lying in the plane. Inset of Fig. 1b provides a schematic representation of the polarization of ferroelectric domains at two electric field states, $|E| = 0.8 \text{ MV m}^{-1}$ (top scheme) and $E = 0 \text{ MV m}^{-1}$ (bottom scheme). At $|E| = 0.8 \text{ MV m}^{-1}$, the c -axis points OOP, as indicated by the main contribution to the (103) peak. However, at $E = 0 \text{ MV m}^{-1}$, XRD measurements reveal the presence of ferroelectric domains with the c -axis oriented in multiple directions, suggesting a random distribution of domains. These findings indicate that BTO(001) substrate used in this work does not exhibit the typical characteristics of a standard BTO with this orientation. In fact, this first characterization highlights the importance of characterizing the ferroelectric substrate prior to the magnetoelectric analysis of the hybrid NiFe/BTO magnetoelectric heterostructure. When the electric field is removed, the disordered arrangement of the BTO ferroelectric domains does not allow the polarization remanence. These results show that BTO has two distinct states: one at null poling, where the domains are randomly oriented, and another with saturated poling, where the domains align with the applied electric field.

The NiFe layer was studied by XRD under various electric fields applied to the heterostructure to analyze how the strain from BTO affects the NiFe lattice. Due to the low XRD intensity of the polycrystalline NiFe layer, reciprocal space measurements were unable to provide information about the IP NiFe lattice parameters and their relationship with the BTO ferroelectric domains. However, in the $\theta-2\theta$ configuration, we previously reported two reflections from our electrodeposited NiFe: (111) and (002).⁴⁷ The NiFe(111) reflection appears at 44.41° , while the BTO(002) reflection is at 44.86° . Due to the



high intensity and width of the BTO peak, we could not resolve the NiFe(111). However, the NiFe(002) reflection is separated from the substrate peaks, allowing for clear analysis. From θ - 2θ measurements, applying Bragg's law ($n\lambda = 2d_{hkl}\sin\theta$) and considering the cubic structure of the NiFe alloy ($a = d_{hkl}\sqrt{h^2 + k^2 + l^2}$), it is possible to achieve information about the OOP lattice parameter. Fig. 1c shows how the (002) NiFe reflection can be shifted by applying an electric field to the heterostructure. At $|E| = 0.8 \text{ MV m}^{-1}$, the NiFe lattice parameter in the OOP direction is 3.548 \AA , while at $E = 0 \text{ MV m}^{-1}$, it is 3.541 \AA . Therefore, when the electric field is applied, the lattice parameter corresponding to the OOP direction increases compared to the no voltage state (inset of Fig. 1c). This increase in the OOP lattice axis with the applied electric field is similar to the behavior observed in BTO, where the ferroelectric domains show the same trend, demonstrating that the strain from BTO is adequately transferred to the NiFe layer. As a result, we can control the NiFe strain state by electrically polarizing the ferroelectric substrate and, due to the NiFe magnetostriction, manipulate its magnetic anisotropy.

Following the structural characterization of the heterostructure, we proceed with the magnetic characterization. The magnetostrictive NiFe layer in its as-grown state was investigated using MOKE (Fig. 2a), revealing the characteristic transcritical hysteresis shape typically associated with stripe domain structures.^{52,53} Additionally, the XMCD-PEEM image shown in Fig. 2b confirms the presence of these stripe domains, exhibiting a periodicity of $\sim 1.4 \mu\text{m}$. This behavior is consistent with the expected formation of stripe domains in electrodeposited $\text{Ni}_{90}\text{Fe}_{10}$ alloys with thickness exceeding 200 nm .⁴⁵ The presence of stripe domains can be quantitatively calculated, taking into account the quality factor Q :

$$Q = \frac{2K_{\text{PMA}}}{\mu_0 M_s^2} \quad (1)$$

where K_{PMA} is the perpendicular magnetic anisotropy (PMA) energy and M_s is the saturation magnetization.⁵⁴ In materials characterized by moderate or low PMA ($Q < 1$), stripe domains

develop when the film thickness exceeds a theoretical critical value t_{cr} :

$$t_{\text{cr}} = 2\pi\sqrt{\frac{A_{\text{ex}}}{K_{\text{PMA}}}} \quad (2)$$

where A_{ex} is the exchange stiffness. If $Q > 0.1$, stripe domains are wider than the layer thickness, whereas for $Q < 0.1$ they exhibit a periodicity equal to the layer thickness.⁵⁴ The K_{PMA} for our samples can be obtained from the IP MOKE loop (Fig. 2a) as:

$$K_{\text{PMA}} = \frac{\mu_0 H_K M_s}{2} \quad (3)$$

where $\mu_0 H_K = 20 \text{ mT}$ is the anisotropy field extracted from experimental measurements, and $M_s = 5.9 \times 10^5 \text{ A m}^{-1}$ for $\text{Ni}_{90}\text{Fe}_{10}$.⁵⁵ A value of $Q = 0.027$ is obtained, consistent with the presence of a low PMA in the as-grown NiFe layer. Furthermore, the fact that the stripe domain periodicity is similar to the layer thickness ($1.5 \mu\text{m}$) also indicates that the system is in the $Q < 0.1$ regime.

Before investigating the magnetoelectric coupling in the NiFe/BTO heterostructure, it is necessary to define the IP directions used in the MOKE analysis. Fig. 3a illustrates the ϕ IP directions, where $\phi = 0^\circ$ ($\phi = 90^\circ$) is parallel to what we call in the following the BTO[010] (BTO[100]) axis. This directional scheme is established within the saturating poling framework, corresponding to the left scheme of Fig. 1b. To evaluate the magnetoelectric coupling between NiFe and BTO, we applied an electric field perpendicular to the heterostructure as depicted in Fig. 1a to observe the resulting magnetic changes using MOKE. Fig. 3b presents the hysteresis loops of the NiFe layer at $\phi = 0^\circ$, comparing the as-grown state with two states achieved after poling: one without poling (0 MV m^{-1}) and another with applied poling (-0.4 MV m^{-1} and 0.4 MV m^{-1}). The 0 MV m^{-1} state (red curve) shows the hysteresis loop after poling the heterostructure and returning to electrical remanence. In this state, the transcritical shape of the as-grown loop disappears, indicating a transition in magnetic anisotropy direction from OOP to IP. Moreover, it indicates that a uniaxial

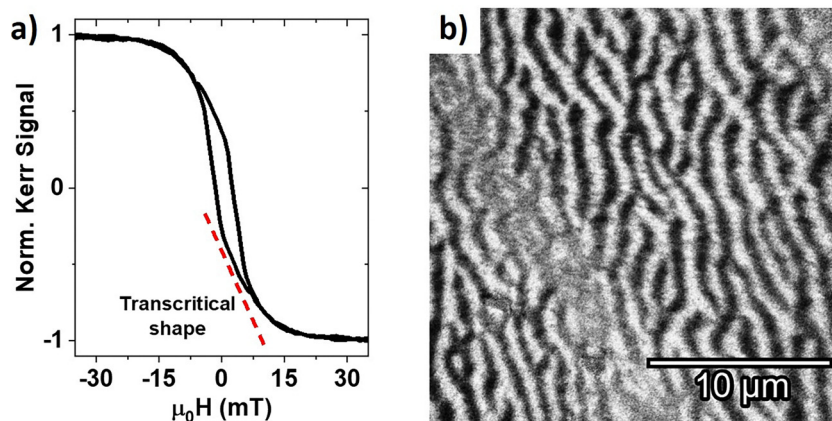


Fig. 2 (a) MOKE hysteresis loop for the as-grown $\text{Ni}_{90}\text{Fe}_{10}$ state, indicating the transcritical shape with a red dashed line. (b) XMCD-PEEM image of $\text{Ni}_{90}\text{Fe}_{10}$ taken at magnetic remanence.



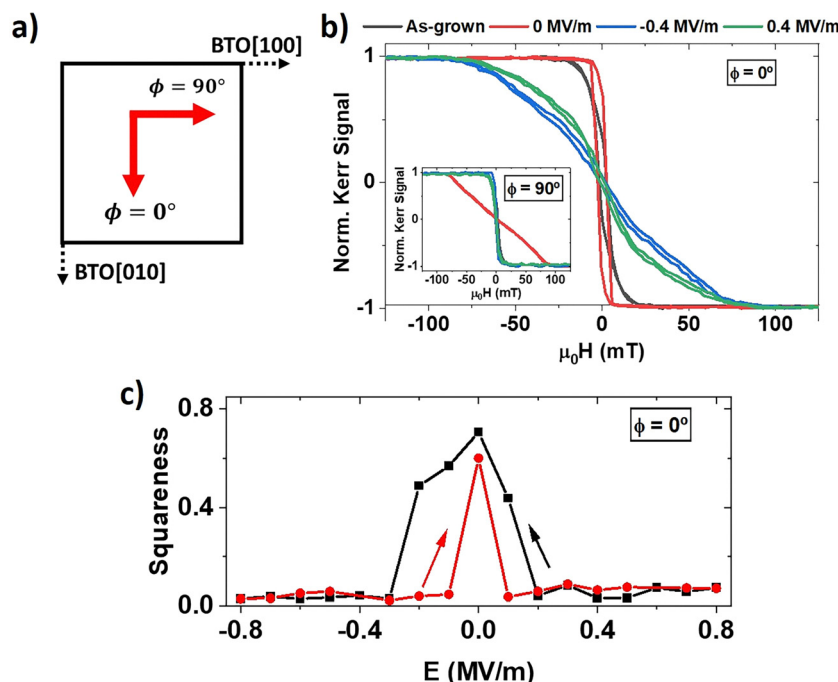


Fig. 3 (a) Schematic top view of the BTO substrate during saturated poling, indicating the IP directions corresponding to ϕ (red arrows) and the BTO crystallographic directions (dashed arrows). (b) MOKE hysteresis loops of the as-grown state and the two states obtained after poling: without an applied electric field (0 MV m^{-1}) and with electric fields of -0.4 MV m^{-1} and 0.4 MV m^{-1} along $\phi = 0^\circ$. Inset along $\phi = 90^\circ$. The line colors in the main figure and inset correspond to the same legend. (c) Squareness versus electric field obtained from several hysteresis loops ($\phi = 0^\circ$). The cycle starts at 0.8 MV m^{-1} (black squares), and the return path from -0.8 MV m^{-1} (red dots) is indicated by arrows for clarity.

anisotropy arises parallel to the substrate directions (see Fig. 3b and the inset at 0 MV m^{-1}), with its easy axis along $\phi = 0^\circ$ and its hard axis along $\phi = 90^\circ$. When a bias is applied, the axis for $\phi = 0^\circ$ changes from easy to hard (Fig. 3b), whereas for $\phi = 90^\circ$, it changes from hard to easy (Fig. 3b inset). From these values, we can estimate the strain transferred from the substrate to the film, assuming that magnetoelastic anisotropy is the sole cause of the change in uniaxial magnetic anisotropy. The minimum strain needed to rotate the uniaxial anisotropy is given by $K_u = K_{me}$, where K_u is the uniaxial anisotropy and K_{me} is the magnetoelastic anisotropy. Using $K_u = \frac{1}{2}\mu_0 H_a M_s$ and $K_{me} = \frac{3}{2}\lambda \varepsilon Y$, with $\mu_0 H_a = 77 \text{ mT}$ (from Fig. 3b), $M_s = 0.65 \text{ MA m}^{-1}$,⁵⁵ and $Y = 216 \text{ GPa}$,⁵⁶ we estimate that the strain ε transferred from the BTO to the NiFe layer is -0.35% . By considering the Poisson's ratio of $\text{Ni}_{90}\text{Fe}_{10}$, which is $\nu \sim 0.22$,⁵⁶ we can estimate that to achieve a rotation of the uniaxial anisotropy, an OOP strain of $-\nu \cdot \varepsilon = -0.22 \times -0.35\% \sim 0.08\%$ is required. From the XRD measurements, we determined that the strain induced in the OOP direction of the NiFe lattice is: $(3.548 - 3.541)/3.548 \times 100 \sim 0.2\%$. Thus, the strain produced in the lattice is more than twice the amount needed to rotate the uniaxial anisotropy. Note that the IP strain is compressive and the OOP strain is tensile, consistent with the expected effects on deformations of isotropic materials. The use of an alloy specifically chosen for its optimal magnetic and mechanical properties, such as the $\text{Ni}_{90}\text{Fe}_{10}$ alloy, enables the

effective utilization of BTO distortion to control its magnetic anisotropy. Fig. 3b confirms a strong magnetoelectric coupling between the layer and the substrate, sufficiently robust to rotate the IP uniaxial anisotropy by 90° . Importantly, these findings are reproducible, demonstrating that the direction of the uniaxial magnetic anisotropy can be effectively controlled through electrical methods, with the easy axis pointing along $\phi = 0^\circ$ without poling and along $\phi = 90^\circ$ when an electric field is applied.

Several hysteresis loops have been studied at different poling fields to investigate the VCMA. Fig. 3c shows the squareness (M_{rem}/M_{sat}) of the cycles obtained in a ferroelectric cycle starting from $+0.8 \text{ MV m}^{-1}$ along the $\phi = 0^\circ$ direction. Low squareness values are associated with a hard axis, while high squareness values correspond to an easier direction. The graph confirms that the magnetic anisotropy of the sample is controlled using an electric field. Additionally, the lack of memory of the ferroelectric domains upon electric field removal allows the magnetic anisotropy to be tailored independently of the previous electric path taken, facilitating the achievement of the desired direction for the IP uniaxial anisotropy simply by either poling the heterostructure or not.

To calculate the converse magnetoelectric coupling, a 0.4 MV m^{-1} poling field is applied, which is sufficient to switch reproducibly from easy to hard axis (Fig. 3c), and we can thus calculate the converse magnetoelectric coupling⁵⁷ as:

$$\alpha_E = \frac{\mu_0 M_s \Delta S}{\Delta E} \quad (4)$$



where $\Delta S = 0.7$ is the variation in squareness in the range $\Delta E = 0.4 \text{ MV m}^{-1}$ of the applied electric field needed to induce the uniaxial anisotropy. From eqn (4) we obtain $\alpha_E = 1.43 \text{ } \mu\text{s m}^{-1}$ for the $\text{Ni}_{90}\text{Fe}_{10}/\text{BTO}$ heterostructure, which exceeds values found in other BTO-based strain-coupled systems that do not contain rare-earth elements by one order of magnitude. For instance, the α_E values for reported epitaxial heterostructures such as Ni/BTO , $\text{Fe}_3\text{O}_4/\text{BTO}$, and $\text{La}_{0.67}\text{Sr}_{0.33}\text{MnO}_3/\text{BTO}$ are $0.09 \text{ } \mu\text{s m}^{-1}$,⁵⁸ $0.1 \text{ } \mu\text{s m}^{-1}$,⁵⁹ and $0.23 \text{ } \mu\text{s m}^{-1}$.⁵⁷ To enable a direct comparison, we refer to the only available α_E values for electrodeposited layers, which, to the best of our knowledge, have only been reported in our previous work on $\text{BTO}(011)$, which achieved $0.205 \text{ } \mu\text{s m}^{-1}$ under the piezoelectric regime.⁴⁸ The main difference between the reported experiments and ours lies in the ferromagnetic layer, whose properties, such as magnetostriiction and anisotropy, were carefully tailored by controlling its thickness, composition, and electrodeposition growth rate to maximize its magnetic response to the strain generated by the BTO. These results are particularly noteworthy because the thick, polycrystalline $\text{Ni}_{90}\text{Fe}_{10}$ layer makes it suitable for technology transfer, paving the way for its use in future VCMA applications.

Conclusions

This study reveals the magnetoelectric coupling in the $\text{Ni}_{90}\text{Fe}_{10}/\text{BTO}(001)$ heterostructure and how it can be exploited to control uniaxial IP magnetic anisotropy through an electric field. The as-grown NiFe layer exhibits weak PMA that changes to uniaxial IP anisotropy when the BTO is poled. The BTO substrate, lacking polarization retention upon electric field removal, results in two distinct ferroelectric configurations: one with random ferroelectric domain orientation and another with all ferroelectric domains aligned in the electric field direction. These two ferroelectric configurations lead to two directions for the IP magnetic anisotropy in the NiFe layer that are 90° apart in the plane, *i.e.* IP uniaxial magnetic anisotropy. This 90° rotation of the IP anisotropy yields a converse magnetoelectric coupling of $1.43 \text{ } \mu\text{s m}^{-1}$, which is one order of magnitude higher than the values reported for other BTO strain-coupled heterostructures reported so far.

Author contributions

The manuscript was written through contributions of all authors. All authors have given approval to the final version of the manuscript. A. Begué: data curation (lead); analysis (lead); investigation (lead); methodology (lead); writing – original draft (lead). M. W. Khaliq: investigation; methodology. N. Cotón: investigation; methodology. I. Lorenzo-Feijoo: investigation; methodology. M. A. Niño: analysis; investigation; methodology; funding acquisition; writing – review & editing. M. Foerster: analysis; investigation; methodology; funding acquisition; writing – review & editing. R. Ranchal: data curation; analysis; investigation; methodology; conceptualization (lead); funding

acquisition; project administration (lead); writing – review & editing.

Conflicts of interest

The authors have no conflicts to disclose.

Data availability

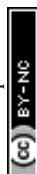
The data that support the findings of this study are available from the corresponding author upon reasonable request.

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References

- 1 K. Cai, M. Yang, H. Ju, S. Wang, Y. Ji, B. Li, K. W. Edmonds, Y. Sheng, B. Zhang, N. Zhang, S. Liu, H. Zheng and K. Wang, Electric field control of deterministic current-induced magnetization switching in a hybrid ferromagnetic/ferroelectric structure, *Nat. Mater.*, 2017, **16**, 712–716.
- 2 H. Meer, F. Schreiber, C. Schmitt, R. Ramos, E. Saitoh, O. Gomonay, J. Sinova, L. Baldrati and M. Kläui, Direct Imaging of Current-Induced Antiferromagnetic Switching Revealing a Pure Thermomagnetoelastic Switching Mechanism in NiO , *Nano Lett.*, 2020, **21**, 114–119.
- 3 P. Wadley, B. Howells, J. Železný, C. Andrews, V. Hills, R. P. Campion, V. Novák, K. Olejník, F. Maccheronzi, S. S. Dhesi, S. Y. Martin, T. Wagner, J. Wunderlich, F. Freimuth, Y. Mokrousov, J. Kuneš, J. S. Chauhan, M. J. Grzybowski, A. W. Rushforth, K. W. Edmonds, B. L. Gallagher and T. Jungwirth, Electrical switching of an antiferromagnet, *Science*, 2016, **351**, 587–590.
- 4 T. Koyama, Y. Nakatani, J. Ieda and D. Chiba, Electric field control of magnetic domain wall motion *via* modulation of the Dzyaloshinskii-Moriya interaction, *Sci. Adv.*, 2018, **4**, 0265.
- 5 S. Fusil, V. Garcia, A. Barthélémy and M. Bibes, Magnetoelectric Devices for Spintronics, *Annu. Rev. Mater. Res.*, 2014, **44**, 91–116.
- 6 L. Herrera Diez, R. Kruk, K. Leistner and J. Sort, Magnetoelectric materials, phenomena, and devices, *APL Mater.*, 2021, **9**, 050401.



- 7 R. Chen and Y. Li, Voltage-Controlled Skyrmionic Interconnect with Multiple Magnetic Information Carriers, *ACS Appl. Mater. Interfaces*, 2022, **14**, 30420–30434.
- 8 W. Kang, Y. Huang, C. Zheng, W. Lv, N. Lei, Y. Zhang, X. Zhang, Y. Zhou and W. Zhao, Voltage Controlled Magnetic Skyrmion Motion for Racetrack Memory, *Sci. Rep.*, 2016, **6**, 23164.
- 9 F. N. Tan, W. L. Gan, C. C. I. Ang, G. D. H. Wong, H. X. Liu, F. Poh and W. S. Lew, High velocity domain wall propagation using voltage controlled magnetic anisotropy, *Sci. Rep.*, 2019, **9**, 7369.
- 10 D. Chiba, M. Kawaguchi, S. Fukami, N. Ishiwata, K. Shimamura, K. Kobayashi and T. Ono, Electric-field control of magnetic domain-wall velocity in ultrathin cobalt with perpendicular magnetization, *Nat. Commun.*, 2012, **3**, 888.
- 11 P. Monalisha, M. Ameziane, I. Spasojevic, E. Pellicer, R. Mansell, E. Menéndez, S. van Dijken and J. Sort, Magnetoelectronics for Synaptic Devices and Neuromorphic Computing: Recent Advances, Challenges, and Future Perspectives, *Small Sci.*, 2024, **4**, 2400133.
- 12 G. Bernard, K. Cottart, M.-A. Syskaki, V. Porée, A. Resta, A. Nicolaou, A. Durnez, S. Ono, A. Mora Hernandez, J. Langer, D. Querlioz and L. Herrera Diez, Dynamic Control of Weight-Update Linearity in Magneto-Ionic Synapses, *Nano Lett.*, 2025, **25**, 1443–1450.
- 13 S. Das, R. Mansell, L. Flajšman, M.-A. Syskaki, J. Langer and S. van Dijken, Magneto-ionic synapse for reservoir computing, *Phys. Rev. Appl.*, 2025, **23**, 054043.
- 14 K. F. Wang, J.-M. Liu and Z. F. Ren, Multiferroicity: the coupling between magnetic and polarization orders, *Adv. Phys.*, 2009, **58**, 321–448.
- 15 N. A. Spaldin and R. Ramesh, Advances in magnetoelectric multiferroics, *Nat. Mater.*, 2019, **18**, 203–212.
- 16 C. N. R. Rao and C. R. Serrao, New routes to multiferroics, *J. Mater. Chem.*, 2007, **17**(47), 4931–4938.
- 17 N. Hur, S. Park, P. A. Sharma, J. S. Ahn, S. Guha and S.-W. Cheong, Electric polarization reversal and memory in a multiferroic material induced by magnetic fields, *Nature*, 2004, **429**, 392–395.
- 18 E. Ascher, H. Rieder, H. Schmid and H. Stössel, Some Properties of Ferromagnetoelectric Nickel-Iodine Boracite, *Ni₃B₇O₁₃I*, *J. Appl. Phys.*, 1966, **37**, 1404–1405.
- 19 V. J. Folen, G. T. Rado and E. W. Stalder, Anisotropy of the Magnetoelectric Effect in Cr₂O₃, *Phys. Rev. Lett.*, 1961, **6**, 607–608.
- 20 R. Gupta, S. Chaudhary and R. K. Kotnala, Interfacial Charge Induced Magnetoelectric Coupling at BiFeO₃/BaTiO₃ Bilayer Interface, *ACS Appl. Mater. Interfaces*, 2015, **7**, 8472–8479.
- 21 Z. Zheng, P. Zhou, Y. Liu, K. Liang, R. G. Tanguturi, H. Chen, G. Srinivasan, Y. Qi and T. Zhang, Strain effect on magnetoelectric coupling of epitaxial NFO/PZT heterostructure, *J. Alloys Compd.*, 2020, **818**, 152871.
- 22 R. O. Cherifi, V. Ivanovskaya, L. C. Phillips, A. Zobelli, I. C. Infante, E. Jacquet, V. Garcia, S. Fusil, P. R. Briddon, N. Guiblin, A. Mougin, A. A. Ünal, F. Kronast, S. Valencia, B. Dkhil, A. Barthélémy and M. Bibes, Electric-field control of magnetic order above room temperature, *Nat. Mater.*, 2014, **13**, 345–351.
- 23 R. Gupta and R. K. Kotnala, A review on current status and mechanisms of room-temperature magnetoelectric coupling in multiferroics for device applications, *J. Mater. Sci.*, 2022, **57**, 12710–12737.
- 24 A. Nicolenco, A. Gómez, X.-Z. Chen, E. Menéndez, J. Fornell, S. Pané, E. Pellicer and J. Sort, Strain gradient mediated magnetoelectricity in Fe-Ga/P(VDF-TrFE) multiferroic bilayers integrated on silicon, *Appl. Mater. Today*, 2020, **19**, 100579.
- 25 C. Song, B. Cui, F. Li, X. Zhou and F. Pan, Recent progress in voltage control of magnetism: Materials, mechanisms, and performance, *Prog. Mater. Sci.*, 2017, **87**, 33–82.
- 26 X. Liang, A. Matyushov, P. Hayes, V. Schell, C. Dong, H. Chen, Y. He, A. Will-Cole, E. Quandt, P. Martins, J. McCord, M. Medarde, S. Lanceros-Mendez, S. van Dijken, N. X. Sun and J. Sort, Roadmap on Magnetoelectric Materials and Devices, *IEEE Trans. Magn.*, 2021, **57**, 1–57.
- 27 J. Ryu, S. Priya, K. Uchino and H.-E. Kim, Magnetoelectric Effect in Composites of Magnetostrictive and Piezoelectric Materials, *J. Electroceram.*, 2002, **8**, 107–119.
- 28 S.-K. Kim, J.-W. Lee, S.-C. Shin, H. W. Song, C. H. Lee and K. No, Voltage control of a magnetization easy axis in piezoelectric/ferromagnetic hybrid films, *J. Magn. Magn. Mater.*, 2003, **267**, 127–132.
- 29 A. Begué and M. Ciria, Strain-Mediated Giant Magnetoelectric Coupling in a Crystalline Multiferroic Heterostructure, *ACS Appl. Mater. Interfaces*, 2021, **13**, 6778–6784.
- 30 L. Leiva, J. L. A. Torres, J. E. Gómez, D. V. Rodríguez, J. Milano and A. Butera, Electric field control of magnetism in FePt/PMN-PT heterostructures, *J. Magn. Magn. Mater.*, 2022, **544**, 168619.
- 31 A. Chen, H.-G. Piao, C. Zhang, X.-P. Ma, H. Algaidi, Y. Ma, Y. Li, D. Zheng, Z. Qiu and X.-X. Zhang, Switching magnetic strip orientation using electric fields, *Mater. Horiz.*, 2023, **10**, 3034–3043.
- 32 M. Buzzi, R. V. Chopdekar, J. L. Hockel, A. Bur, T. Wu, N. Pilet, P. Warnicke, G. P. Carman, L. J. Heyderman and F. Nolting, Single Domain Spin Manipulation by Electric Fields in Strain Coupled Artificial Multiferroic Nanostructures, *Phys. Rev. Lett.*, 2013, **111**, 027204.
- 33 S. Finizio, M. Foerster, M. Buzzi, B. Krüger, M. Jourdan, C. A. F. Vaz, J. Hockel, T. Miyawaki, A. Tkach, S. Valencia, F. Kronast, G. P. Carman, F. Nolting and M. Kläui, Magnetic Anisotropy Engineering in Thin Film Ni Nanostructures by Magnetoelastic Coupling, *Phys. Rev. Appl.*, 2014, **1**, 021001.
- 34 F. Rubio-Marcos, A. D. Campo, P. Marchet and J. F. Fernández, Ferroelectric domain wall motion induced by polarized light, *Nat. Commun.*, 2015, **6**, 6594.
- 35 F. Rubio-Marcos, D. A. Ochoa, A. D. Campo, M. A. García, G. R. Castro, J. F. Fernández and J. E. García, Reversible optical control of macroscopic polarization in ferroelectrics, *Nat. Photonics*, 2017, **12**, 29–32.



- 36 A. Bagri, A. Jana, G. Panchal, D. M. Phase and R. J. Choudhary, Amalgamation of Photostriction, Photodomain, and Photopolarization Effects in BaTiO₃ and Its Electronic Origin, *ACS Appl. Electron. Mater.*, 2022, **4**, 4438–4445.
- 37 M. Ghidini, F. Maccherozzi, X. Moya, L. C. Phillips, W. Yan, J. Soussi, N. Métallier, M. E. Vickers, N. Steinke, R. Mansell, C. H. W. Barnes, S. S. Dheshi and N. D. Mathur, Perpendicular Local Magnetization Under Voltage Control in Ni Films on Ferroelectric BaTiO₃ Substrates, *Adv. Mater.*, 2015, **27**, 1460–1465.
- 38 A. Bagri, A. Jana, G. Panchal, S. Chowdhury, R. Raj, M. Kumar, M. Gupta, V. R. Reddy, D. M. Phase and R. J. Choudhary, Light-Controlled Magnetoelastic Effects in Ni/BaTiO₃ Heterostructures, *ACS Appl. Mater. Interfaces*, 2023, **15**, 18391–18401.
- 39 R. V. Chopdekar and Y. Suzuki, Magnetoelectric coupling in epitaxial CoFe₂O₄ on BaTiO₃, *Appl. Phys. Lett.*, 2006, **89**, 182506.
- 40 S. Sahoo, S. Polisetty, C.-G. Duan, S. S. Jaswal, E. Y. Tsymbal and C. Binek, Ferroelectric control of magnetism in BaTiO₃ heterostructures via interface strain coupling, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2007, **76**, 092108.
- 41 Z. Q. Liu, L. Li, Z. Gai, J. D. Clarkson, S. L. Hsu, A. T. Wong, L. S. Fan, M.-W. Lin, C. M. Rouleau, T. Z. Ward, H. N. Lee, A. S. Sefat, H. M. Christen and R. Ramesh, Full Electroresistance Modulation in a Mixed-Phase Metallic Alloy, *Phys. Rev. Lett.*, 2016, **116**, 097203.
- 42 Y. Xie, Q. Zhan, Y. Liu, G. Dai, H. Yang, Z. Zuo, B. Chen, B. Wang, Y. Zhang, X. Rong and R.-W. Li, Electric-field control of magnetic anisotropy in Fe₈₁Ga₁₉/BaTiO₃ heterostructure films, *AIP Adv.*, 2014, **4**, 117113.
- 43 T. Brintlinger, S.-H. Lim, K. H. Baloch, P. Alexander, Y. Qi, J. Barry, J. Melngailis, L. Salamanca-Riba, I. Takeuchi and J. Cumings, In Situ Observation of Reversible Nanomagnetic Switching Induced by Electric Fields, *Nano Lett.*, 2010, **10**, 1219–1223.
- 44 R. Grössinger, R. S. Turtelli and N. Mehmood, Materials with high magnetostriction, *IOP Conf. Ser.: Mater. Sci. Eng.*, 2014, **60**, 012002.
- 45 N. Cotón, J. P. Andrés, E. Molina, M. Jaafar and R. Ranchal, Stripe domains in electrodeposited Ni₉₀Fe₁₀ thin films, *J. Magn. Magn. Mater.*, 2023, **565**, 170246.
- 46 S. Priya, R. Islam, S. Dong and D. Viehland, Recent advancements in magnetoelectric particulate and laminate composites, *J. Electroceram.*, 2007, **19**, 149–166.
- 47 A. Begué, N. Cotón and R. Ranchal, Magnetic anisotropy evolution with Fe content in electrodeposited Ni₁₀₀–xFe_x thin films, *J. Mater. Chem. C*, 2024, **12**, 10104–10109.
- 48 A. Begue, M. W. Khaliq, N. Cotón, M. Á. Niño, M. Foerster and R. Ranchal, Voltage-control of the in-plane magnetic anisotropy in hybrid magnetoelectric Ni₉₀Fe₁₀/BaTiO₃(011) heterostructure, *J. Mater. Chem. C*, 2025, **13**, 5287–5294.
- 49 N. Cotón, J. P. Andrés, M. Jaafar, A. Begué and R. Ranchal, Tuning the out-of-plane magnetic textures of electrodeposited Ni₉₀Fe₁₀ thin films, *J. Appl. Phys.*, 2024, **135**, 093905.
- 50 J. Lyu, I. Fina, R. Solanas, J. Fontcuberta and F. Sánchez, Tailoring Lattice Strain and Ferroelectric Polarization of Epitaxial BaTiO₃ Thin Films on Si(001), *Sci. Rep.*, 2018, **8**, 495.
- 51 L. Aballe, M. Foerster, E. Pellegrin, J. Nicolas and S. Ferrer, The ALBA spectroscopic LEEM-PEEM experimental station: layout and performance, *J. Synchrotron Radiat.*, 2015, **22**, 745–752.
- 52 N. Saito, H. Fujiwara and Y. Sugita, A New Type of Magnetic Domain Structure in Negative Magnetostriction Ni-Fe Films, *J. Phys. Soc. Jpn.*, 1964, **19**, 1116–1125.
- 53 L.-C. Garnier, M. Marangolo, M. Eddrief, D. Bisero, S. Fin, F. Casoli, M. G. Pini, A. Rettori and S. Tacchi, Stripe domains reorientation in ferromagnetic films with perpendicular magnetic anisotropy, *J. Phys.: Mater.*, 2020, **3**, 024001.
- 54 A. Hubert, in *Magnetic domains: The Analysis of Magnetic Microstructures*, ed. R. Schäfer, Springer, Berlin, 1st edn, 1998.
- 55 B. D. Cullity, in *Introduction to magnetic materials*, ed. C. D. Graham, IEEE/Wiley, Hoboken, NJ, 2nd edn, 2009.
- 56 H. M. Ledbetter and R. P. Reed, Elastic Properties of Metals and Alloys, I. Iron, Nickel, and Iron-Nickel Alloys, *J. Phys. Chem. Ref. Data*, 1973, **2**, 531–618.
- 57 W. Eerenstein, M. Wiora, J. L. Prieto, J. F. Scott and N. D. Mathur, Giant sharp and persistent converse magnetoelectric effects in multiferroic epitaxial heterostructures, *Nat. Mater.*, 2007, **6**, 348–351.
- 58 T. Buttler, T. Walther, K. Dörr and S. G. Ebbinghaus, Preparation and Magnetoelectric Behavior of Ni/BaTiO₃ Heterostructures with 0-3 Connectivity, *Phys. Status Solidi B*, 2020, **257**, 1900622.
- 59 R. Revathy, N. Kalarikkal, M. R. Varma and K. P. Surendran, Exotic magnetic properties and enhanced magnetoelectric coupling in Fe₃O₄–BaTiO₃ heterostructures, *J. Alloys Compd.*, 2021, **889**, 161667.

